3				
	5	118/715-733.ccls. and ((vafer substrate)	USPAT;	2003/06/09 09:05
		<pre>with (marrier holder) with (attach\$3 secur\$3) with spindle)</pre>	US-PGPUB	
4	330	118/715-753.ccls. and ((wafer substrate)	USPAT;	2003/05/09 03:09
		with (darrier holder) with (attach\$3 secura3))	US-PGPUB	
10	62	118/7:9.ccls. and ((water substrate) with	UCPAT;	2003 16 09 09:09
-	343	(darrier holder) with (attach\$3 secur\$3)) 118/715-733.ccls. and ((liner shutter	US-PGPUB USPAT;	2003/05/09/08:43
_	271	shield) with (cylinder cylindrical\$3)) 118,715-733.ccls. and (liner shutter	US-PGPUB USPAT;	2003/06/08 16:02
		snield) with cocl\$30	US-PGPUE	
-	263	118/715-736.ccls. and liner shutter shield: with (reactor chamber)) and appricalas.	USPAT; US-PGPUE	2003/06/08 15:07
-	3.3	• •	USPAT;	1 2003 16708 15:05
		snield) with (reactor chamber) with (annular cylindrical) cylinder)) and	US-PGPUB	
_	174	applied.as. (118/715-733.cols. and cliner snutter	JSPAT;	1303706/08 15:25
	2	shield with (reactor chamber)) and	US-PGPUB	
		applied.as.) not (11-/715-733.ccls. and		
		((liner shutter shield, with (reactor chamber) with (annular evilondrical)		
		cylinder and applied.as.)		
-	2.0		USFAT	2003/06/08 15:32
		US-6000114-\$ or US-6.000170-\$ or US-6.00170-\$ or US-6.00140-\$ or US-6000100-\$ or		
		US-898177/-\$ or US-6 61\$ or	ļ	
		US-6143038+\$ or US-6.23231-\$ or		i
		US-r. 6401s or US-6102617-3).did. (:US-6107121-3 or US-6202591-3 or	USFAT;	: .nots/
!		100	US-PGPUF	. U. C. 10
!		US-ALU7140-\$ or US-6131732-\$ or		
		02-5451777-\$ or 03-6151120-\$ or 02-6145034-\$ or 03-617171-\$ or		
		U3-8164811-\$ or US-8181817-\$).did.) and		
_	Á	0001 (:US-n197121-\$ or US-6202591-\$ or	USFAT;	1.003 9 6 98 18:32
		U3-rail6-\$ or U8-6118171-\$ or	US-PGPUF	1
		U3-6.17140-\$ or U3-6.51751-\$ or		Á
		US-8981778-\$ or US-6981102-\$ or US-6148086-\$ or US-6111001-\$ or		
		US-62%4812-\$ or US-61%(807-\$).did.) and		
-	28	GOOLS	USFAT	.003 6:08 15:55
-		5788V-4. UMEN. and copus?	USFAT; US-PGPUE	.003 06/08 15:46
-	e**	######################################	EFC; JEC; DEFWENT	1003,00,08 15:56
-	35741	(:lara: shutter shield with (ccols3	USFAT;	. 663 (6, 68 16:68
-	6284	annular oylindridal\$ oylinder): c28c(148.ipc.	US-PGPUF USFAT;	.003-06-08-16:07
_	53026	hllifils.ipc.	US-PGPUP USFAT;	1003 06:08 16:07
			US-PGPUE	
_	5463	(deposit\$% etch\$% "cvd" layer film) same ((liner shutter srield with (ccol\$% annular cylingrical\$ cynger))	USFAT; US-PGPUF	2003 (6.08 16:06
-	(ı	(c20c-16\$.ipc. h011)210.ipc. (and	EFC; JPC;	2003/66 08 16:06
İ		((laner shutter shield) with (ccol\$3 annular cylindrical\$ cylinder):	DEFWENT	
- ;	0	(6256 16\$.ipc. h0110210.ipc. c and	EFC; JFC;	2003.06/08 16:06
ı		((lungr shutter shield) with (cool\$3) with	DEFWENT	1
-	(1	(annular cylindrical\$ cylinder)) (c23c-16\$.ipc. h011021\$.ipc.) and	 LFC; JFC;	2003/06/08 16:47
		((liner slutter shield) same (cool\$3) same	DERWENT	
_	48231	(annular cylindrical\$ cylinder)) c23c016\$rc.	 EPO; JPC;	 2003/06/68 16:u7
	1 .7. 31		DERWENT	

-	742974	h011021\$.ipc.	EPO; JPO;	.:003/06/08 18:08
			DEPWENT	
-	3.1	(c23c016\$.ipc. h011021\$.ipc.) and	EPO; JPO;	2003/06/08 16:07
		((liner shutter shield) same (cool\$3) same	DEFWENT	
		(annular cylindrical\$ cylinder))		
-	(1	20.21.335.6.011211.	USFAT	L003/06/08 16:31
-] 1	("6111055").PN.	USPAT;	1003/06/08 17:26
			US-PGPUB	
-	1	("pll.::25").PN.	USFAT;	1.003/06/08 17:26
			US-PGPUE	
-	15	h011021\$.ipc. and (reactor with "stainless	EPO; JPO;	1:003/06/08 17:08
		steel")	DEFWENT	
-	634	h011011\$.ipc. and ((multiple plural\$3)	EPC; JPC;	2003/06/08 18:10
		with (wafer substrate, with carrier)	DEFWENT	
-	84	118/718.ccls. and ((multiple plural\$3)	USFAT;	2003/06/08 18:15
1	4.0	with wafer substrate with holder)	US-PGPUE	
-	4.2	118/708.ccls. and ((multiple plural\$3)	USFAT;	2003/06/08 18:11
	_	with (wafer substrate, with carrier)	US-PGPUB	
-	, ,	118/718.ccls. and ((multiple plural\$3)	USPAT;	0003/06/08 18:06
		with (wafer substrate, with holder) and	US-PGPUE	
	0.1	118,719.ccls.		
-	8.1	((multiple plural\$3) with (wafer	USFAT;	2003/06/08 18:16
	0.1	substrate) with holder) and 118/719.ccls.	US-PGPUE	
-	24	((multiple plural\$3) with (wafer	USPAT;	2003,06/08 18:17
		substrate) with holder with (transfer\$4	US-PGPUF	
		transport\$3)) and 118/719.ccls.	110000	1 0005 05 06 16 65
_	3.5	118/715-733.ccls. and ((wafer substrate)	USPAT;	2003,06,08 18:30
1		with holder) with (secur\$3 attach\$3) with	US-PGPUE	
		(spindle rctat\$3))	1	!